

#### ReRAM for Fast Storage Application

Amigo (Keiichi) Tsutsui Sony Corporation



### Adaptive ReRAM Technology for 2014

Cu+ source layer

Thin insulator

Lower Electrode

Cupper filament ( Φ< 10nm )

Word Line NMOS
Transistor

- ✓ Cost: < DRAM
- √ Capacity: > 10Gbit
- ✓ Read: > 1GB/s,
- **✓** Program Endurance:
- ✓ Data Retention:

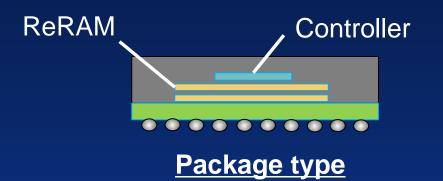
Program: > 200MB/s

> 10<sup>5</sup> cycles

> 10 years



## ReRAM System Module





**Small board type** 

√ Capacity: 4GB ~ 8GB (multi dies)

✓ Access: 512B

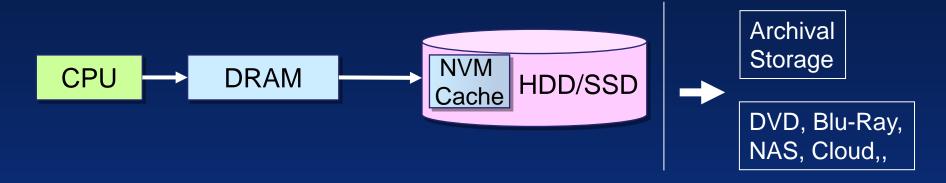
✓ Host IF: PCle, or any high speed IF

✓ Read: 2 ~ 4GB/s, 2 ~ 4us latency

√ Write: 400 ~ 800MB/s, 6 ~ 12us latency



# NVM cache & tier application (1)

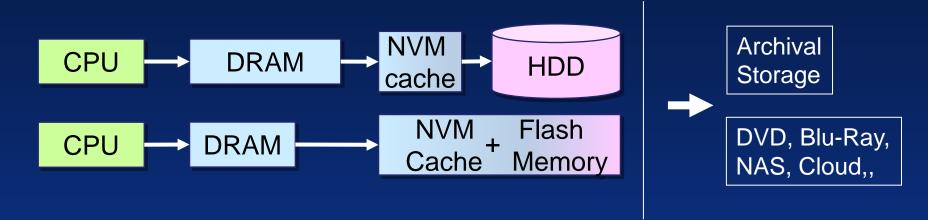


- DRAM replacement: low power, high throughput
  - Throughput is originally depend on HDD and NAND speed)

Chuo Univ. Dr. Takeuchi on VLSI symposium 2012 "Hybrid ReRAM/MLC NAND SSDs by Data Fragmentation Suppression" x11 Performance, x6.9 Endurance, 93% Energy Reduction



## NVM cache & tier application (2)



- SSD replacement: low power, high throughput
  - Download OS & main application beyond ultrabook
- DRAM & Storage replacement: ultra low power, low cost
  - SNS is main storage
  - high speed NVM cover small DRAM capacity



# Thank you!

For questions, please contact
Amigo Tsutsui
Keiichi.Tsutsui@jp.sony.com